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04-18-94  
62

08/212434

Docket 68529APL

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Neil F. Haley, et al

RADIATION-SENSITIVE  
COMPOSITION CONTAINING A  
RESOLE RESIN, A NOVOLAC  
RESIN, AN INFRARED  
ABSORBER AND A TRIAZINE  
AND USE THEREOF IN  
LITHOGRAPHIC PRINTING  
PLATES

Serial No.

Filed herewith

Group Art Unit:

Examiner:

I hereby certify that this correspondence is being  
deposited today with the United States Postal Services  
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Mary Lou Altman  
Name

*Mary Lou Altman*  
Signature

*March 14, 1994*  
Date of Signature

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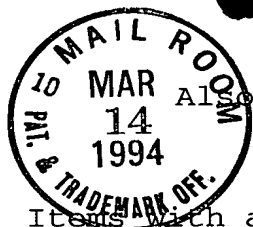
Honorable Commissioner of Patents and Trademarks  
Washington, D.C. 20231

Sir:

DISCLOSURE STATEMENT FOR PATENT AND TRADEMARK  
OFFICE CONSIDERATION UNDER 37 C.F.R. 1.97-1.99

The above-described application cites patents and/or publications for consideration by the Patent and Trademark Office in regard to the claimed invention and indicates the pertinency of these documents to the invention. In compliance with the Patent and Trademark Office Rule 56, such documents are listed in Table 1 below, together with any additional documents which Applicants wish to cite for such consideration. Accompanying each citation is a reference to the page(s) in the above-identified application where each item is discussed, or, if not discussed in the application, a discussion indicating its pertinency to the invention.

By this notice Applicants request that the Patent and Trademark Office make of record the above-identified documents. Unless otherwise indicated, a full text copy of each document is attached. For documents not in English, an English translation is also attached. Where specifically indicated, an equivalent English language patent or publication is attached in lieu of a translation. No representation is made that more pertinent material is not available or should not be considered by the examiner. It is expected that the Patent and Trademark Office will conduct independently a complete search of appropriate prior art.



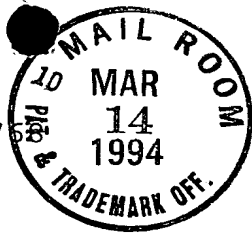
Also enclosed is a completed form PTO-1449.

Table 1

Items with an asterisk (\*) were cited in a foreign Patent Office Communication.

<u>CITED DOCUMENTS</u>	<u>APPLICATION PAGE OR DISCUSSION</u>
U.S. 3,779,778	Page 9.
U.S. 4,160,671	Describes the use of triazines in a radiation-sensitive composition containing a diazide and an organic dye.
U.S. 4,189,323	Describes the use of triazines in a radiation-sensitive composition containing a compound whose solubility is changed by the action of an acid.
U.S. 4,458,000	Describes the use of a triazine in a radiation-sensitive composition comprising a compound containing at least one C-O-C bond cleavable by acid.
U.S. 4,696,888	Describes the use of certain triazines as photoinitiators or photolytic acid donors.
U.S. 4,708,925	Pages 3 and 4.
U.S. 4,842,990	Describes the use of triazines in a radiation-sensitive composition containing a compound possessing at least one C-O-C bond.
U.S. 4,927,732	Describes the use of triazines as photolytic acid donors.
U.S. 4,927,741	Pages 3 and 4.
U.S. 5,017,462	Describes a radiation-sensitive composition containing a quinonediazide, a binder and a triazine.
U.S. 5,084,372	Describes the use of triazines in radiation-sensitive compositions.
U.S. 5,091,287	Describes the use of haloalkyl triazines as photosensitizers in radiation-sensitive compositions.

U.S. 5,100,758




British 2,082,339

Describes the use of triazines in photosensitive compositions containing an alkali-soluble phenolic polymer.  
Pages 3 and 4.

Respectfully submitted,

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Enclosures

  
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